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Date : July 13, 2007

TO : Director, Office of Patent Publication

FROM : Office of Petitions

SUBJECT : Withdrawal from Issue of **Application No. 10/706,902**

Applicant(s) : Hee Yeop Chae et al
Application No. : 10/706,902
Filed : November 12, 2003

The above-identified application has been assigned Patent No. 7,247,253 and an issue date of July 24, 2007.

It is hereby directed that this application be withdrawn from issue at the request of the applicant. Do not refund the issue fee.

The following erratum should be published in the Official Gazette if the above-identified application is published in the OG of July 24, 2007:

"All reference to Patent No. 7,247,253 to Hee Yeop Chae et al of California for SELECTIVE ETCH PROCESS OF A SACRIFICIAL LIGHT ABSORBING MATERIAL (SLAM) OVER A DIELECTRIC MATERIAL appearing in the Official Gazette of July 24, 2007 should be deleted since no patent was granted."

Karen Creasy
Karen Creasy
Petitions Examiner
Office of Petitions

cc: Paul Harrison
Deneise Boyd
Mary Louise McAskill
Niomi Farmer
Mary E. Johnson (Cookie)
Duane Davis (CDS)
Brad Harris
Kim Terrell
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